

Characterizing Nanopattern Formation of Polymer Thin Films on Silicon Substrates with Ion Beam Sputtering

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Introduction

- Ion Beam Sputtering (IBS) has previously been observed to create nanopatterns on the surface of materials
- Formation of patterns on polymer films by ion bombardment is **not yet understood**

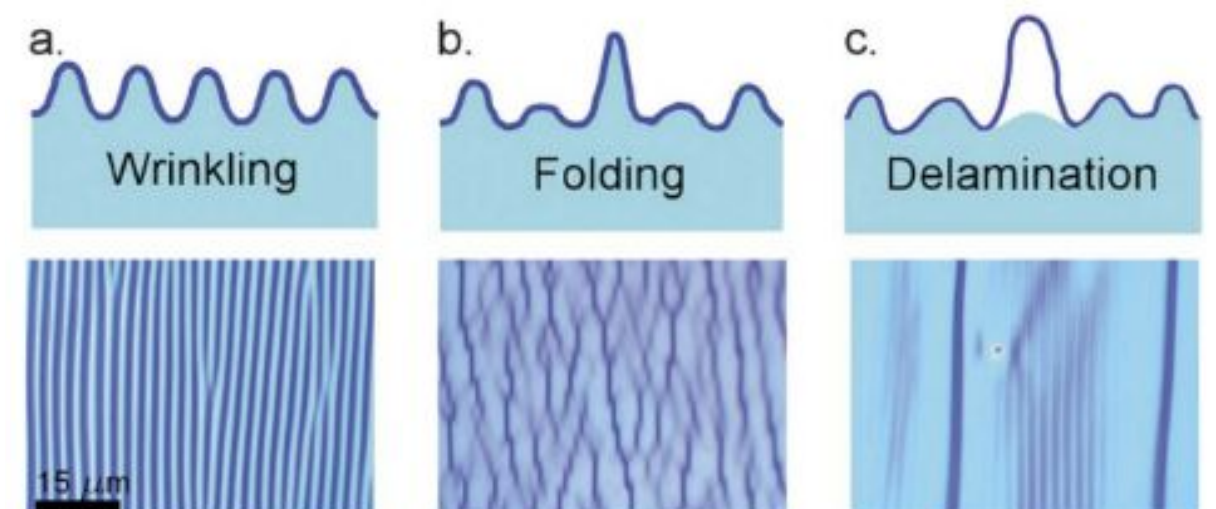


Figure 1. Different types of pattern formation known to be correlated with ion bombardment [1]

- Poly(4-Vinylpyridine) (4-VP) and Polystyrene (PS) polymer thin films on Silicon substrates were selected

- Structurally similar
- Differ by a single aromatic Nitrogen atom only present in 4-VP

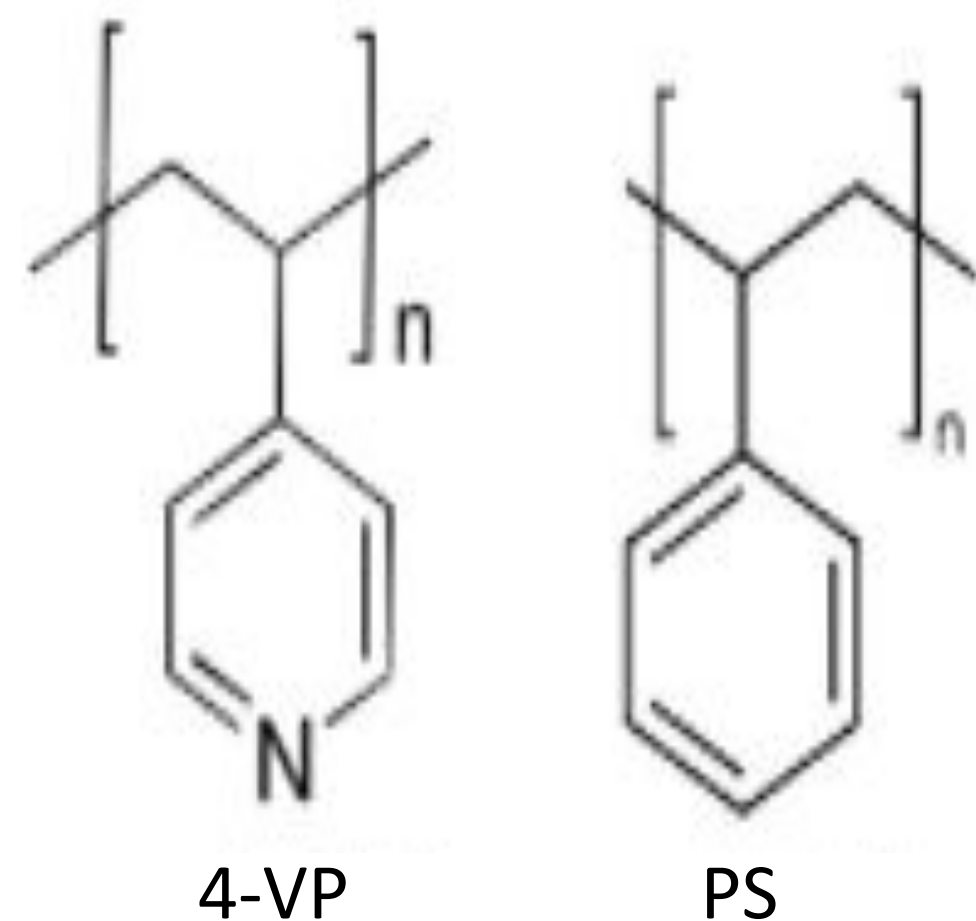


Figure 2. Poly(4-Vinylpyridine) (4-VP) [2]

Figure 3. Polystyrene (PS) [3]

Methods

1. iCVD (Chemical Vapor Deposition)

iCVD (performed by Ince's group) was first used to deposit a uniform layer of polymer on top of the Silicon substrate.

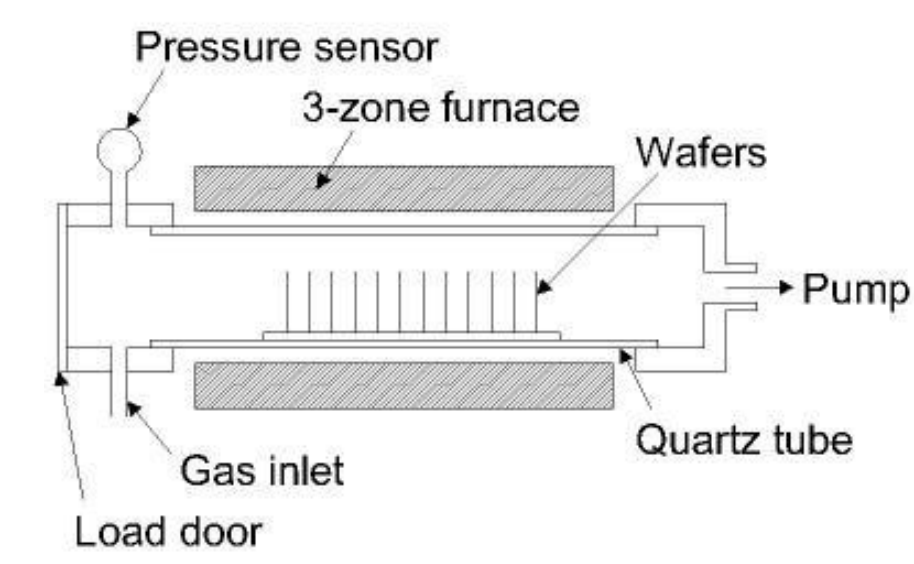


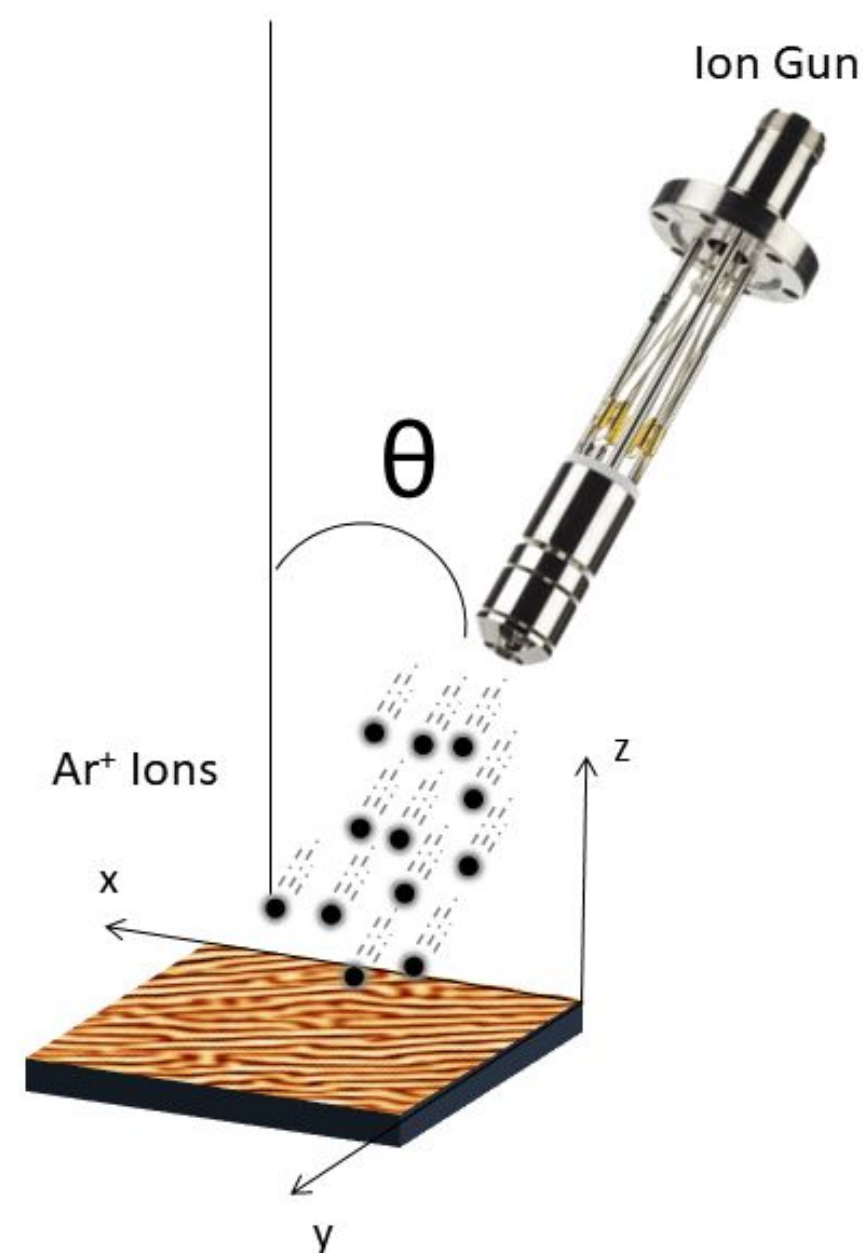
Figure 4. Chemical Vapor Deposition Process [4]

2. Ion Beam Sputtering (IBS)

Using an ion gun, samples were bombarded with Ar⁺ ions

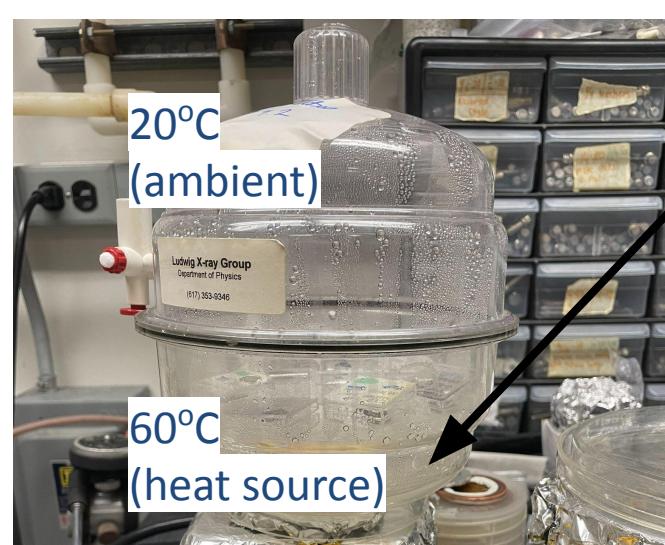
- Incidence Angles (θ):**
- normal incidence (0°)
 - off-axis incidence (50° or 70°)

Ion Energy: 2000 eV
Operating Pressure: 5.00E-05 Torr
Exposure Time: 60 minutes
Flux: ~2.0E+13 Ar⁺/cm²*s



3. Humid Environment vs. Dry Desiccator

After bombardment, samples are placed into either a humid environment (left) or a dry desiccator (right)



Humid Environment
 Slightly acidic water (pH 4.2) placed in chamber below samples



Dry Desiccator
 Polycarbonate drierite creates dry environment

4. Atomic Force Microscopy (AFM)

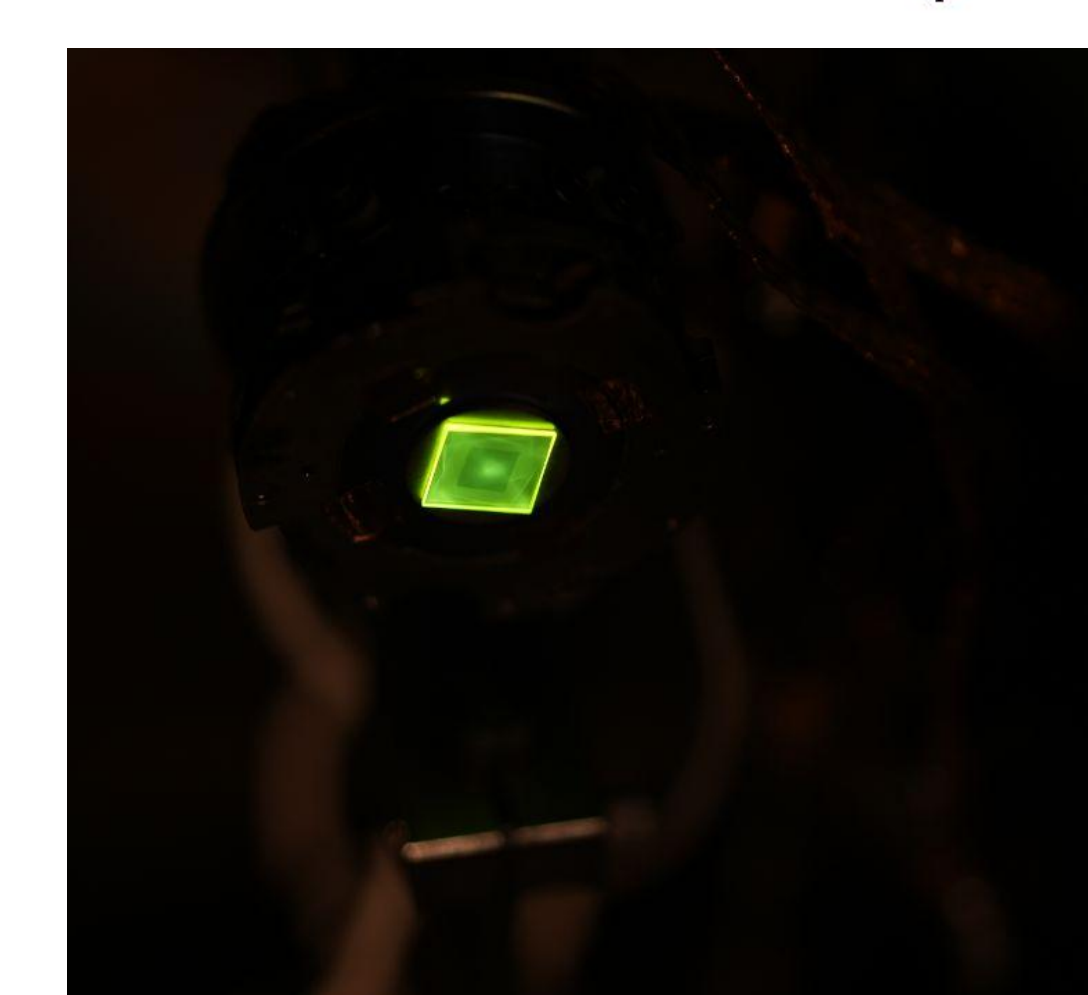
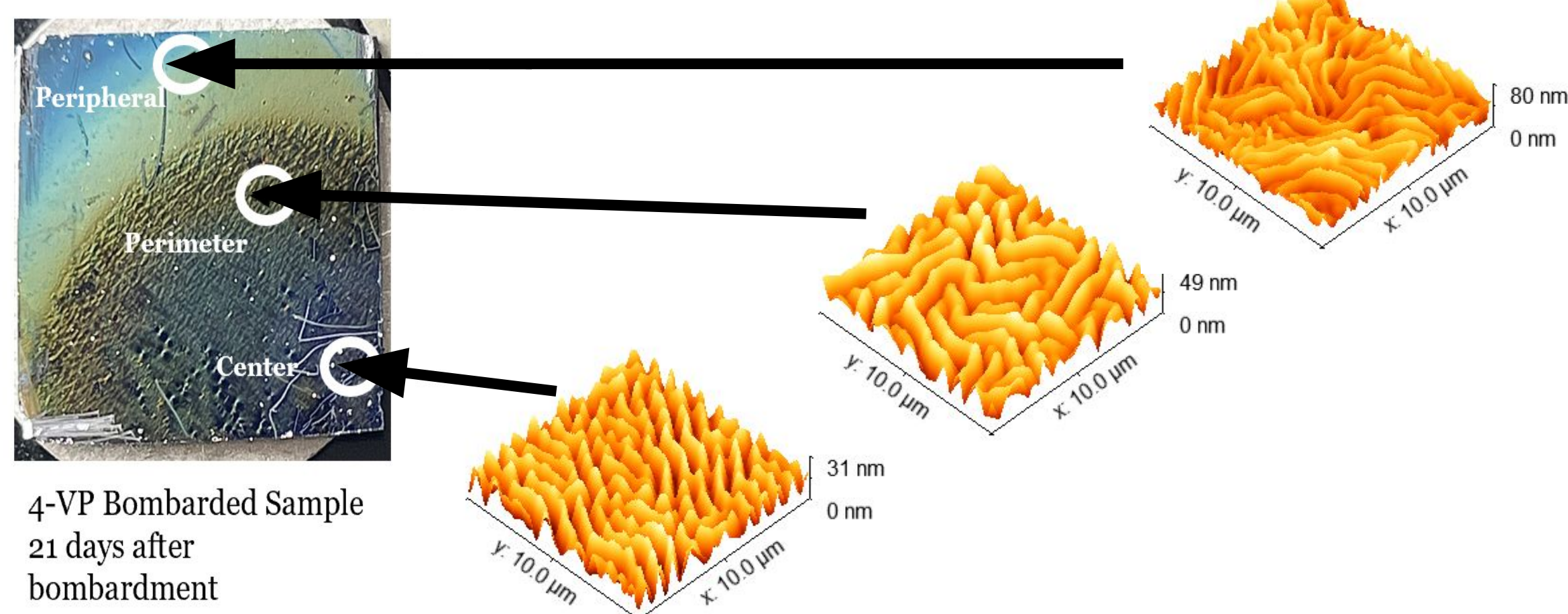


Figure 5. Image of the Ce:YAG crystal with ion beam focus adjust at 2(45) and 0° bombardment

- Edges of the sample received a **lower ion fluence / less concentrated beam**
- Ce:YAG crystal glowing **non-uniformly**
- **Fluorescence intensity at edge is low**

5. Optical Microscopy (OM), Raman Microscopy, Contact Angle Measurements

Results

Optical Microscopy (OM) Images (from A. Nikiforov)

- Figures shown are of 4-VP sample placed in humidity at room temperature
- **Fluid pockets** formed in conditions with increase in absolute humidity (by increasing temperature)
 - Near these pockets, wrinkles aligned radially (Fig. 6)
 - **Delamination** occurs when **fluid pockets popped** (Fig. 7)
- **None of these surface features were seen on Polystyrene samples in humidity**

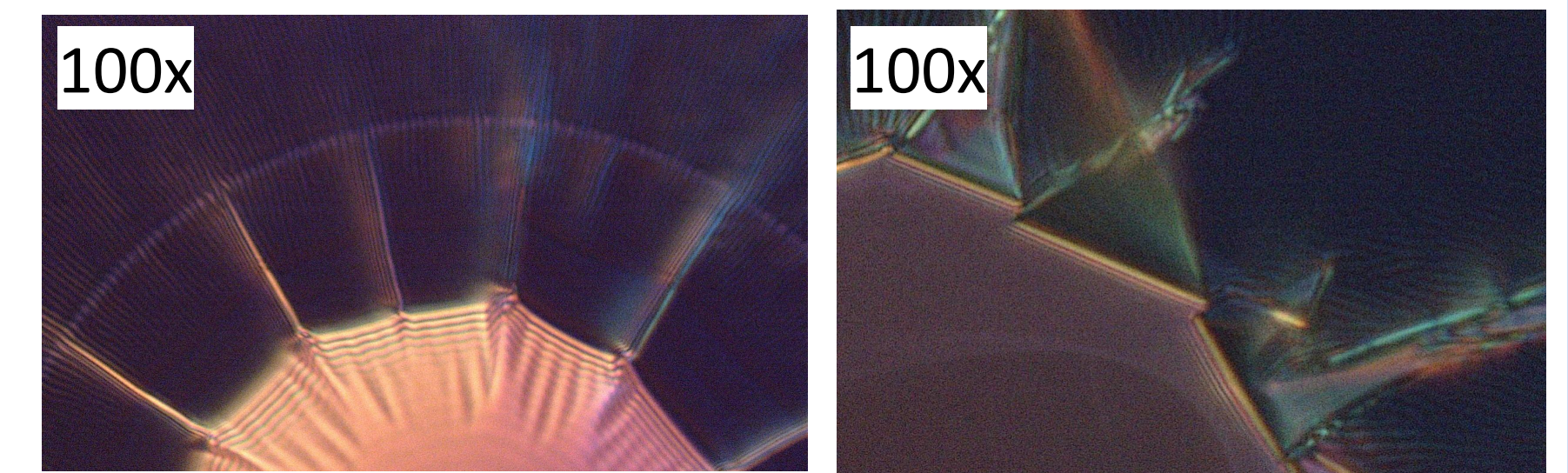
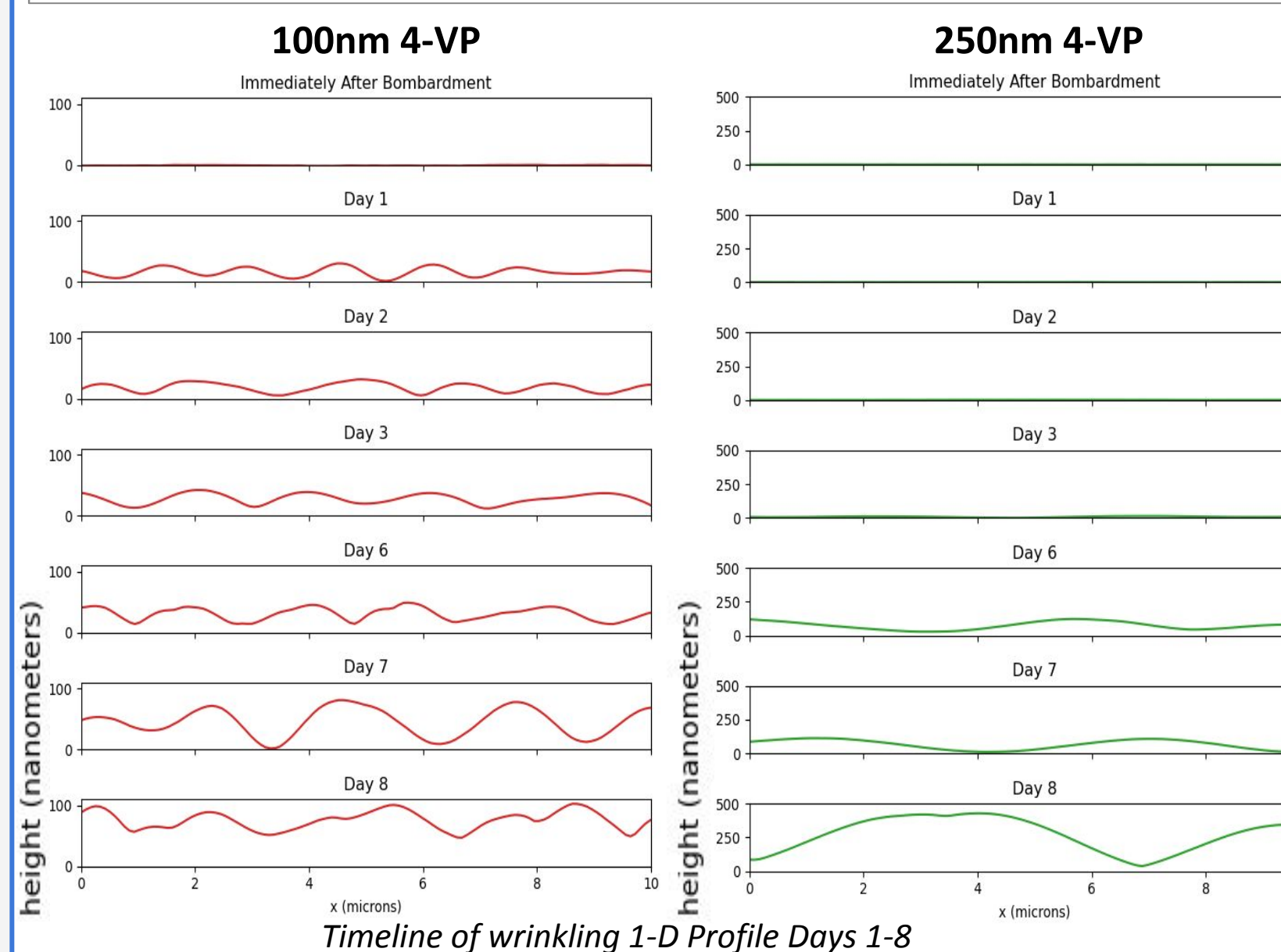
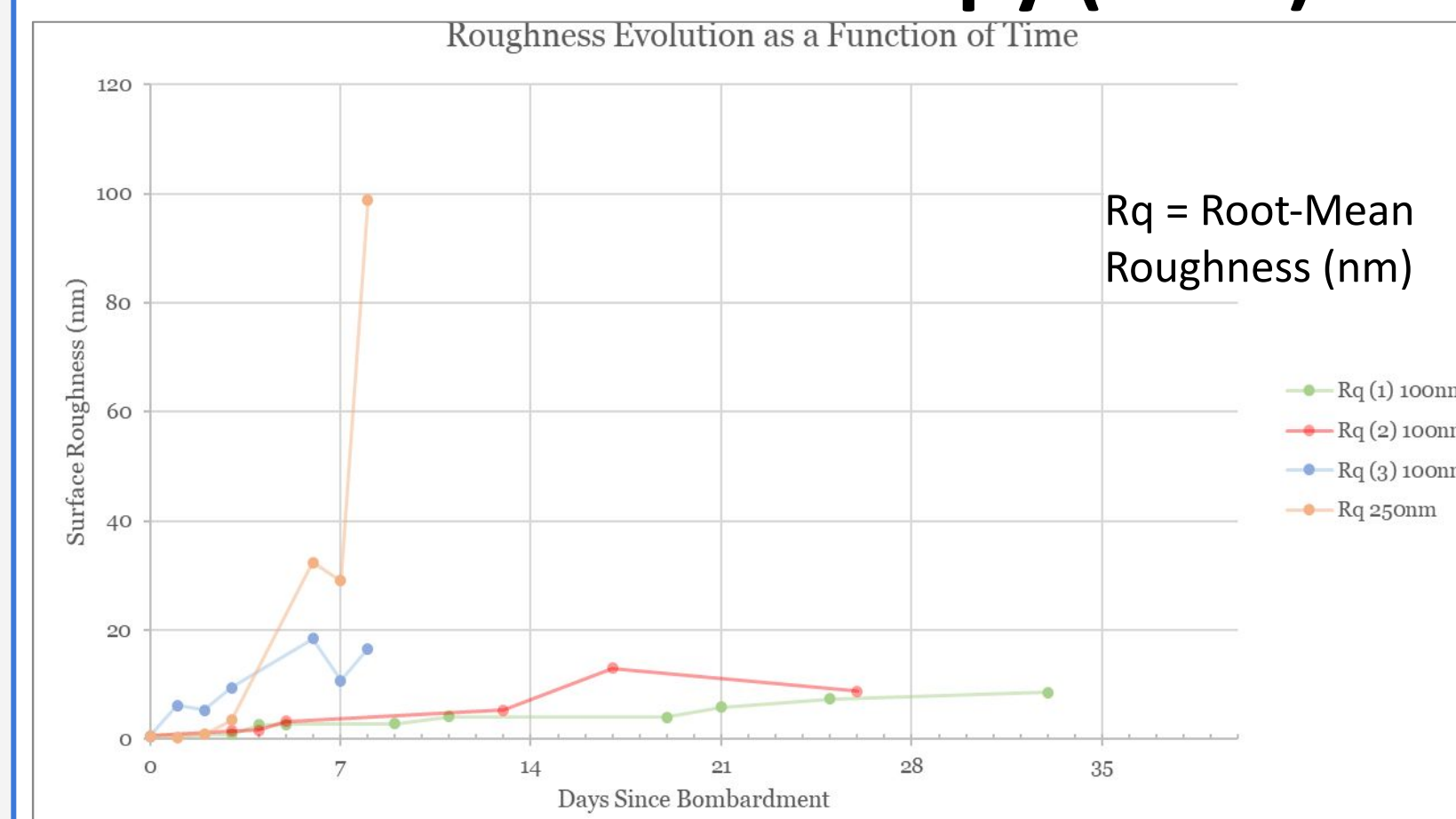


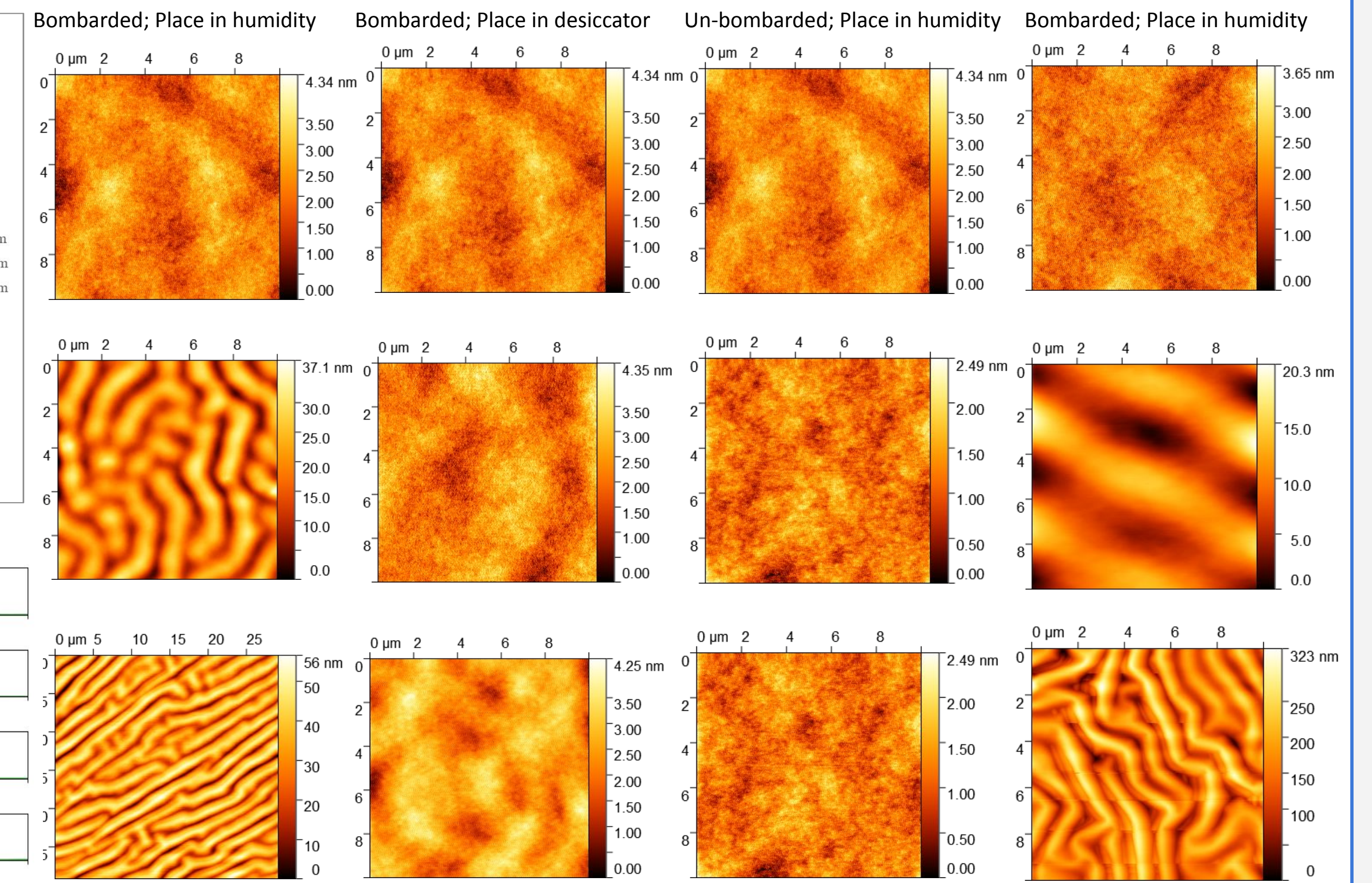
Figure 6. Fluid pockets with radial wrinkling on 4-VP

Figure 7. Delamination on 4-VP

Atomic Force Microscopy (AFM)



AFM Progression of 4-VP (100nm thickness) Over Time

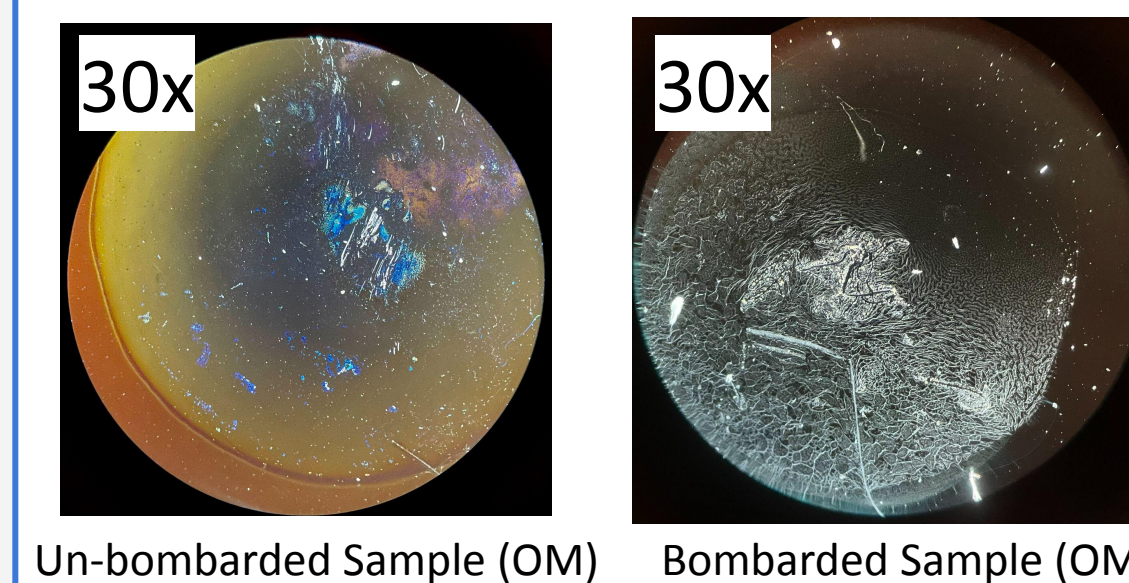


- For **both film thicknesses** of 100nm and 250nm, only samples that were **bombarded** and subsequently placed in **humidity** saw **formation of nanopatterns**
- Samples wrinkled **faster after decreasing the absolute humidity of the humid environment** (from roughly 23g/m³ to 17g/m³)

2-D Fast Fourier Transform (FFT)

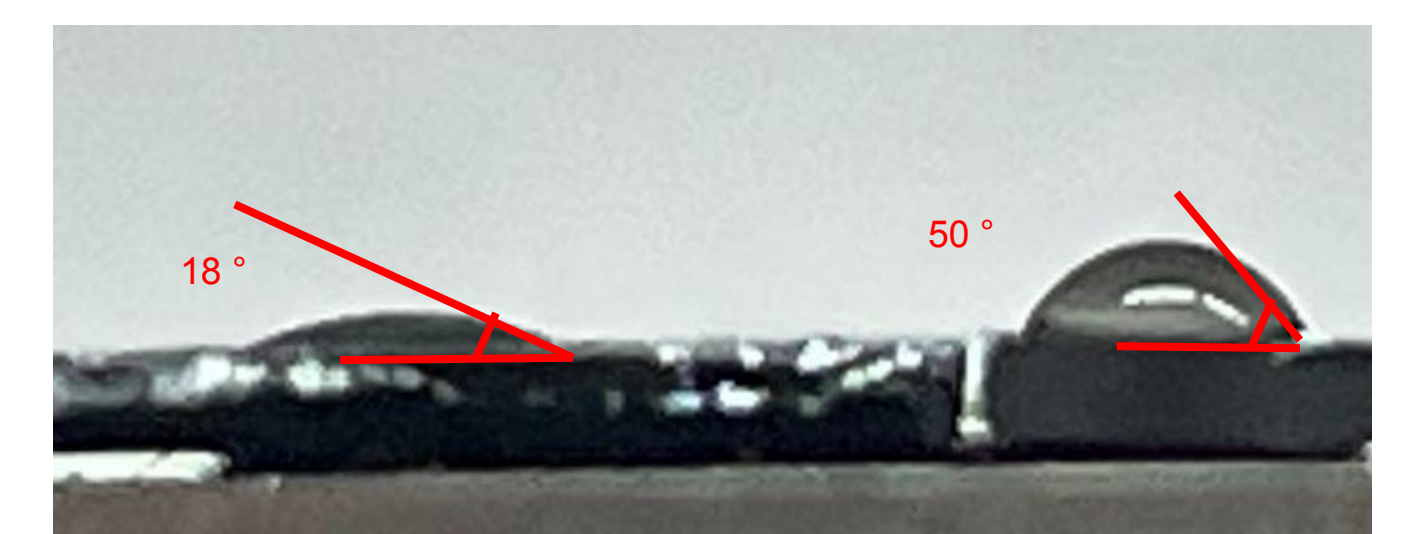
- **100nm 4-VP** has most frequent wrinkle wavelength of **~1.2 microns**
- **250nm 4-VP** has most frequent wrinkle wavelength of **~4 microns**
- **Increase in polymer film thickness increases wavelength of wrinkles**

Contact Angle

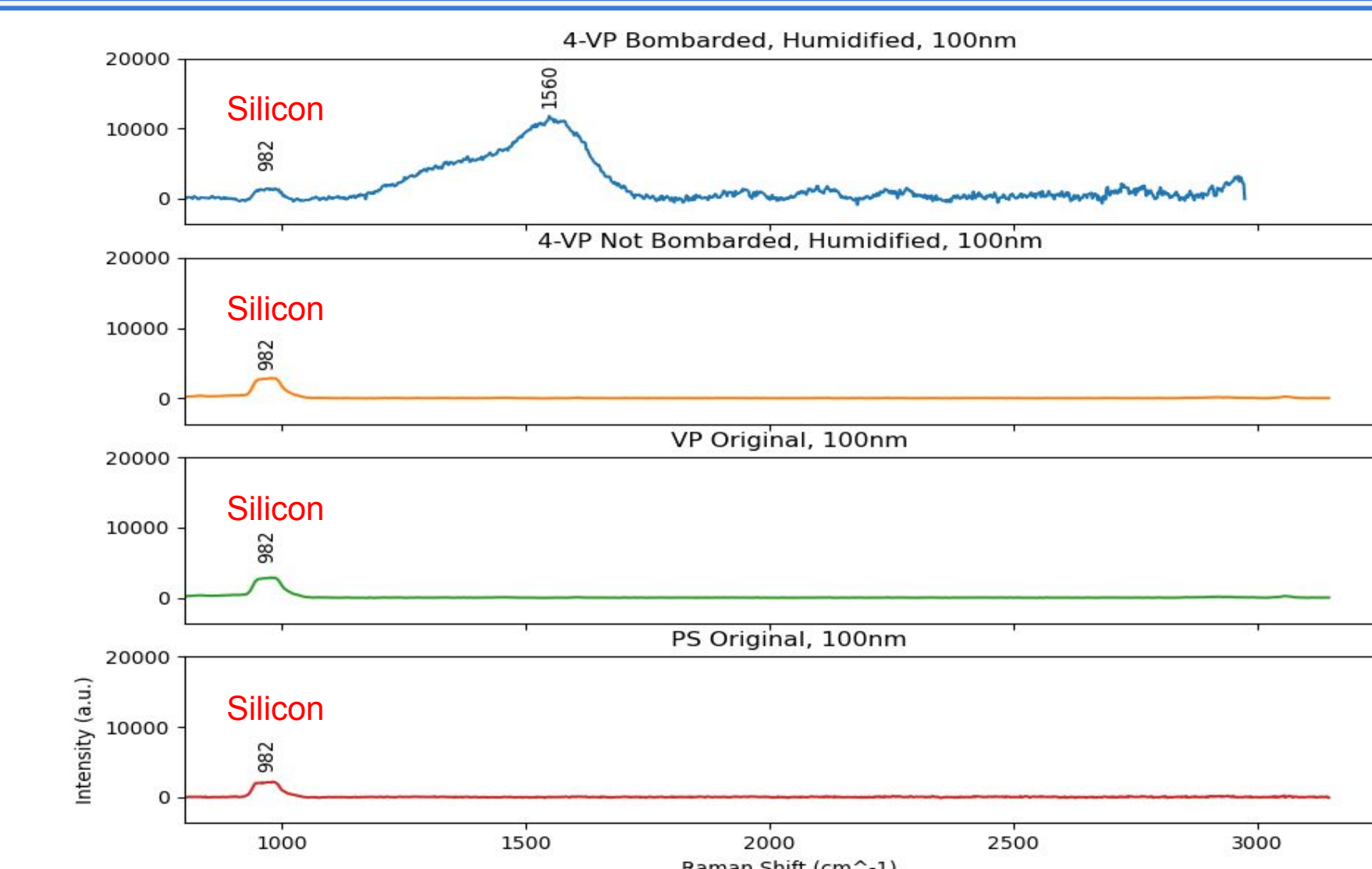


Un-bombarded Sample (OM) Bombarded Sample (OM)

- Water drop on un-bombarded sample degraded surface, no nanoscale patterns formed
- Water drop on bombarded sample left visible wrinkling, surface features too large to see on AFM



Optical Microscopy (OM) images of bombarded sample (right) consistently had a greater contact angle than the un-bombarded sample (left)



Raman Spectroscopy

- Clear peak change after wrinkling
 - Could be attributed to **absorbance of water**
- Peak at 1560nm similar to **aromatic Nitrogen** and / or **H-O-H bending mode** but isn't conclusively either
- Indeterminate signal above 3000nm **repeatable** in many samples, difficult to capture
 - Could be a **weak O-H stretch signal from water content** as well
- Weak signal from thinness of films reveals little about structure of polymers themselves, leading to flat regions in other spectra

Discussion / Conclusions

- **Water and ion exposure** are required for **wrinkling**
 - **Too much ion exposure** causes **less ordered wrinkling**
 - Areas of **lower ion fluence** have **less ordered wrinkling**
- Ion bombardment is associated with **increase in contact angle, decrease in surface wettability, more hydrophobic**
- Raman peaks likely due to water signal
 - 4-VP is pH responsive
 - Indicates change on the molecular level because they are likely **absorbing slightly acidic water after bombardment and humidification**

Acknowledgements

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References

- [1] Ebata, Yuri, et al. "Wrinkling and Strain Localizations in Polymer Thin Films." *Soft Matter*, 26 July 2012. pub.rs.org/en/content/articlelanding/2012/SM/c2sm25859e#divCitation.
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